

P/1071-1500



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of

Takashi HASEGAWA

Serial No.: Not Known

Filed: Not Known

New York, New York

Date: December 19, 2001

Group Art Unit: Not Known

Examiner: Not Known

For: METHOD FOR MANUFACTURING NONRECIPROCAL CIRCUIT DEVICE,
NONRECIPROCAL CIRCUIT DEVICE, AND COMMUNICATION APPARATUS
INCORPORATING

Hon. Commissioner of Patents and Trademarks
Washington, D.C. 20231

SUBMISSION

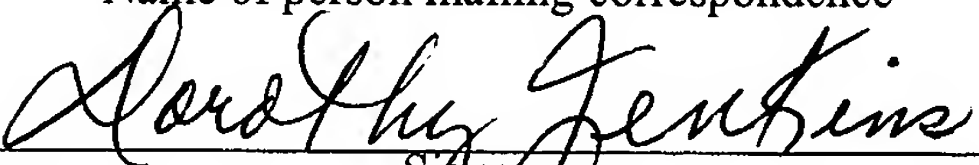
Sir:

Submitted herewith is a copy of art together with a form listing the same
for the convenience of the Examiner.

I hereby certify that this correspondence is being
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19, 2001

Dorothy Jenkins

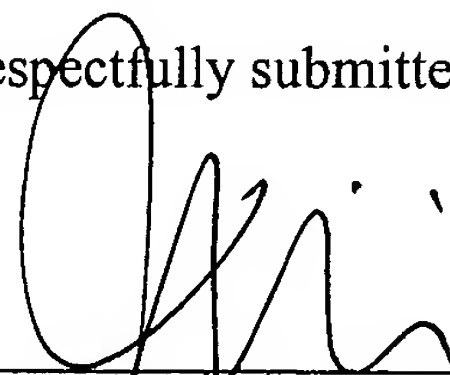
Name of person mailing correspondence


Signature

December 19, 2001

Date of Signature

Respectfully submitted,



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Enclosures

APPLICANT'S ART CITATION (Use several sheets if necessary)	Application Not Known	OFGS File No. P/1071-1500
	Applicant Takashi HASEGAWA	
	Filing Date Not Known	Group Art Unit Not Known

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10/026511
12/19/01

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number							Date	Name	Class	Sub-class	Filing Date If Appropriate

FOREIGN PATENT DOCUMENTS

	Document Number							Date	Country	Class	Sub-class	Translation	
												Yes	No
	10	0	4	1	7	0	6	2/13/1998	JAPAN			ABSTRACT	
	10	2	4	2	7	1	3	11/9/1998	JAPAN			ABSTRACT	

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

Examiner	Date Considered
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.